



IPW

PATENT
8028-1060

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Ryuji KOBAYASHI

Conf. 4993

Application No. 10/580,683

Group 2828

Filed May 26, 2006

Examiner Xinning Niu

SEMICONDUCTOR LASER AND METHOD OF MANUFACTURING THE SAME

SUPPLEMENTAL AMENDMENT

Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

July 9, 2008

Sir:

In response to the Official Action of December 6, 2007,
and supplemental to the amendment filed May 5, 2008, please amend
the above-identified application as follows:

Amendments to the Claims are reflected in the listing
of claims which begins on page 2 of this paper.

Remarks begin on page 10 of this paper.